

JC14 Rec'd PCT/PTO 23 MAR 2005

FORM PTO-1449 (REV. 7-80)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET No. 39907/GM/lp		APPLICATION No. Still unknown <b>10/528775</b>	
<b>INFORMATION DISCLOSURE STATEMENT</b> (use several sheets if necessary)				APPLICANTS <b>MGM 10/528378</b> <b>Massimiliano CAVALLINI - Fabio BISCARINI</b>			
				FILING DATE Still unknown		GROUP ART UNIT Still unknown	

  

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA						
	AB						
	AC						
	AD						
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	AH						
	AI						
	AJ						
	AK						

  

FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
<b>MGM</b>	AL	A- 96/29629	09-1996	WIPO			
	AM						
	AN						
	AO						
	AP						

  

OTHER PRIOR ART (including Author, Title, Date, Pertinent Pages, Etc.)			
<b>MGM</b>	<b>AR</b>		B. MESSER ET AL: "Microchannel networks for Nanowire Patterning" J. AM.CHEM. SOC., vol. 122, 29 September 2000 (2000-09-29), pages 10232-10233, XP002274037 the whole document
<b>MGM</b>	<b>AS</b>		O. CHERNIAVSKAYA ET AL.: "Edge Transfer Lithography of Molecular and Nanoparticle Materials" LANGMUIR (USA), LANGMUIR, AMERICAN CHEM. SOC, USA, vol. 18, 9 August 2002 (2002-08-09), pages 7029-77034, XP002274038 ISSN: 0743-7463 the whole document
<b>MGM</b>	<b>AT</b>		XIA Y ET AL: "SOFT LITHOGRAPHY ANNUAL REVIEW OF MATERIALS SCIENCE, ANNUAL REVIEWS INC., PALO ALTO, CA, US, vol. 28, 1998, pages 153-184, XP009023786 ISSN: 0084-6600 page 173 - page 174; figure 5d
EXAMINER <div style="text-align: center;">/Matthew Marini/</div>			DATE CONSIDERED <div style="text-align: center;">10/02/2006</div>

\* EXAMINER: Initial if reference considered, whether or not criteria is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).

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MGM	AR	CHOU S Y ET AL: "LITHOGRAPHY INDUCED SELF-CONSTRUCTION OF POLYMER MICROSTRUCTURES FOR RESISTLESS PATTERNING" APPLIED PHYSICS LETTERS, AMERICAN INSTITUTE OF PHYSICS. NEW YORK, US, vol. 75, no. 7, 16 August 1999 (1999-08-16), pages 1004-1006, XP000875558 ISSN: 0003-6951
MGM	AS	DESHPANDE P ET AL: "Lithographically induced self-assembly of microstructures with a liquid-filled gap between the mask and polymer surface" J. VAC SCI. TECHNOL. B, MICROELECTRON. NANOMETER STRUCT. (USA), JOURNAL OF VACUUM SCIENCE & TECHNOLOGY B (MICROELECTRONICS AND NANOMETER STRUCTURES), NOV. 2001, AIP FOR AMERICAN VACUUM SOC, USA, vol. 19, no. 6, December 2001 (2001-12), pages 2741-2744, XP002274039 ISSN: 0734-211X cited in the application
	AT	

EXAMINER /Matthew Marini/	DATE CONSIDERED 09/19/2006
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